



***A Picosecond Passively Mode-locked Vertical
(Extended Cavity) Surface Emitting Diode Laser***

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Introduction and Motivation

Some History:

- edge emitting diode lasers modelocked both passively and actively (e.g. NEC 'hybrid' modelocked laser, $\tau_p \sim 2$ psec)

But, modelocking on VCSELs offers benefits for on-chip geometry, ease of integration with micro/optoelectronics, and high density arrays

So far for VCSELs:

- active modelocking work in 1990's (Bowers, Ebeling)
- optically pumped high-power passively modelocked extended cavity VCSELs (Keller)

Now:

- passively modelocked (extended cavity) VCSEL diode
- challenge: device design and implementation in a vertical diode; SESAM

Why: applications from chipscale all-optical processors to bioinstrumentation



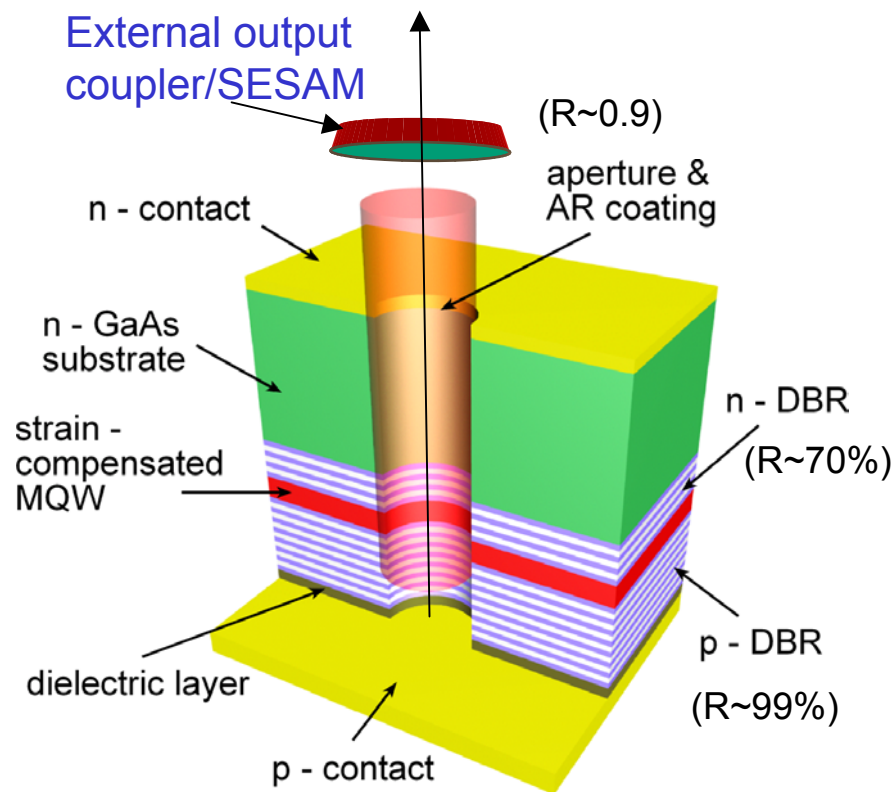
Challenge of Passively Modelocking a Diode VCSEL

- 1) Resonator configuration: saturation of absorption vs. gain
- 2) Compatibility with electrical transport
- 3) Design of the saturable absorber

Device base: A Large Aperture Extended Cavity VCSEL (Novalux Inc); $\lambda \sim 980$ nm

- 3-mirror coupled-cavity configuration design for large aperture, high power operation; substrate part of resonator
- MOCVD grown GaInAs/GaAsP strain-compensated multiple QWs gain medium
- TEM₀₀ mode size controlled by extended cavity and internal aperture (50- 150 μ m)
- Monolithic integration has been achieved

Device Idea:

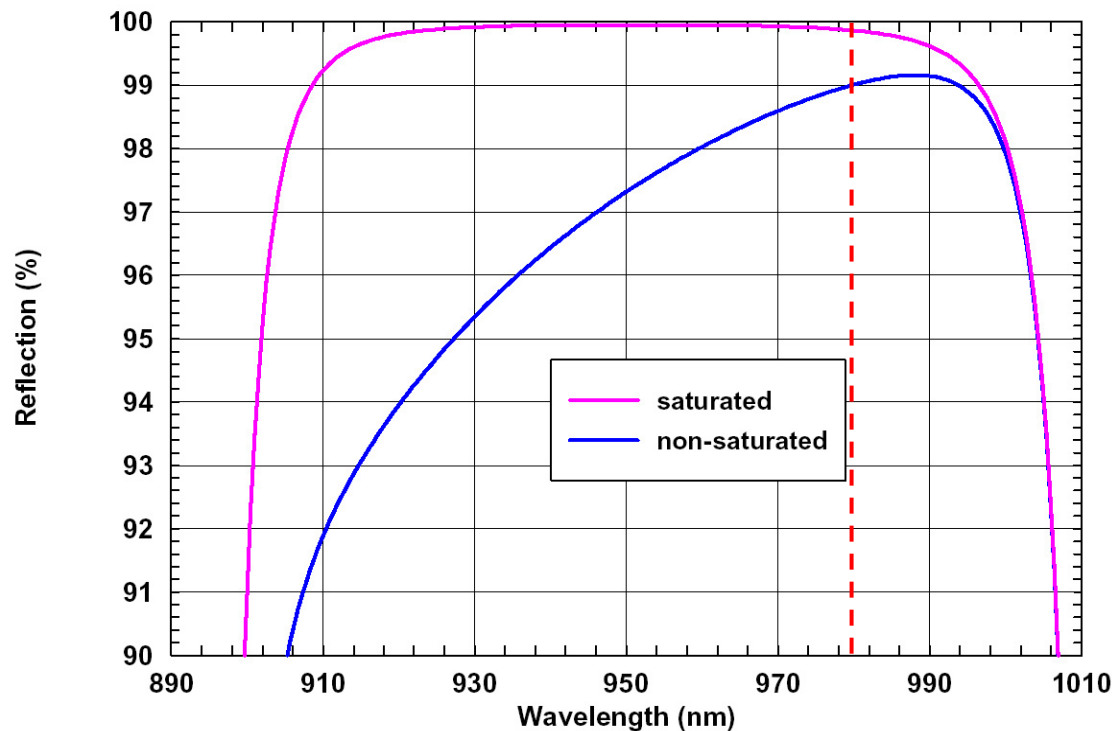
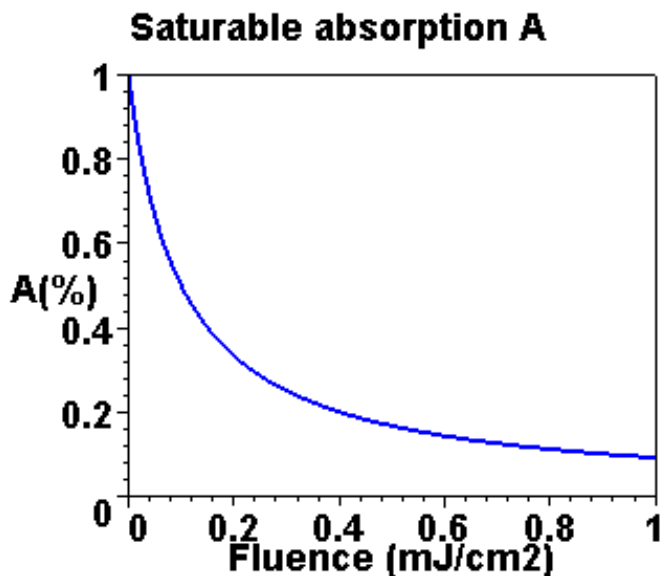
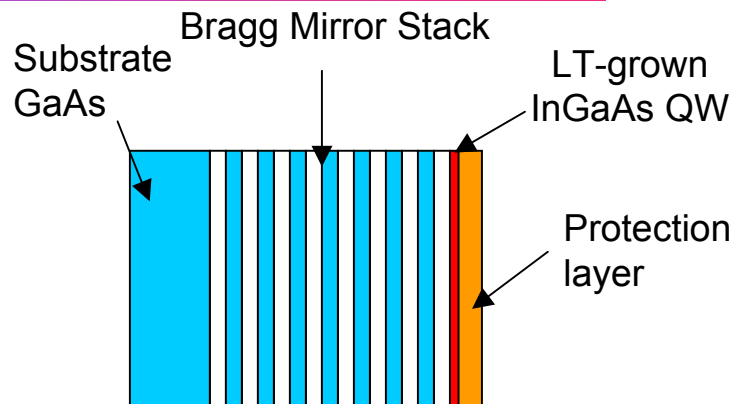




Semiconductor Saturable Absorber Mirror (SESAM)

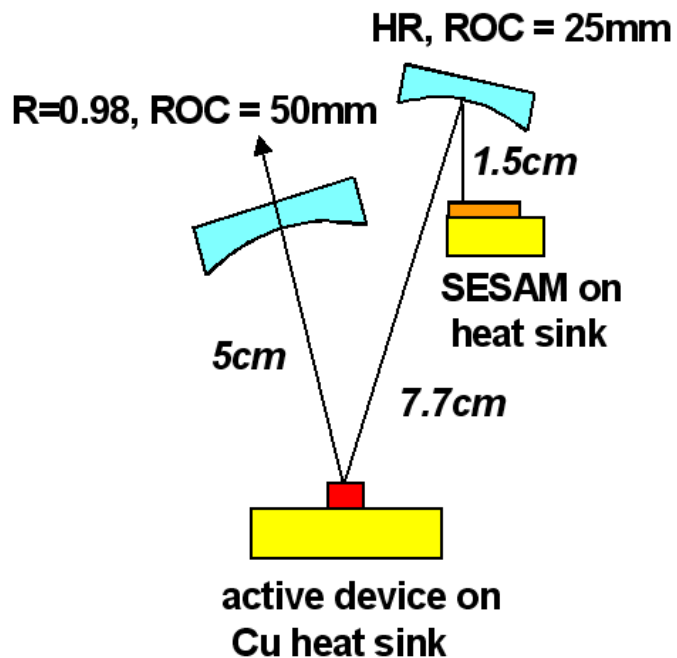
(W.Richter, Weimar)

| | |
|-----------------------------|---|
| Saturable absorption | 1% |
| Saturation fluence | $70\mu\text{J}/\text{cm}^2$ |
| Relaxation time | 20ps |

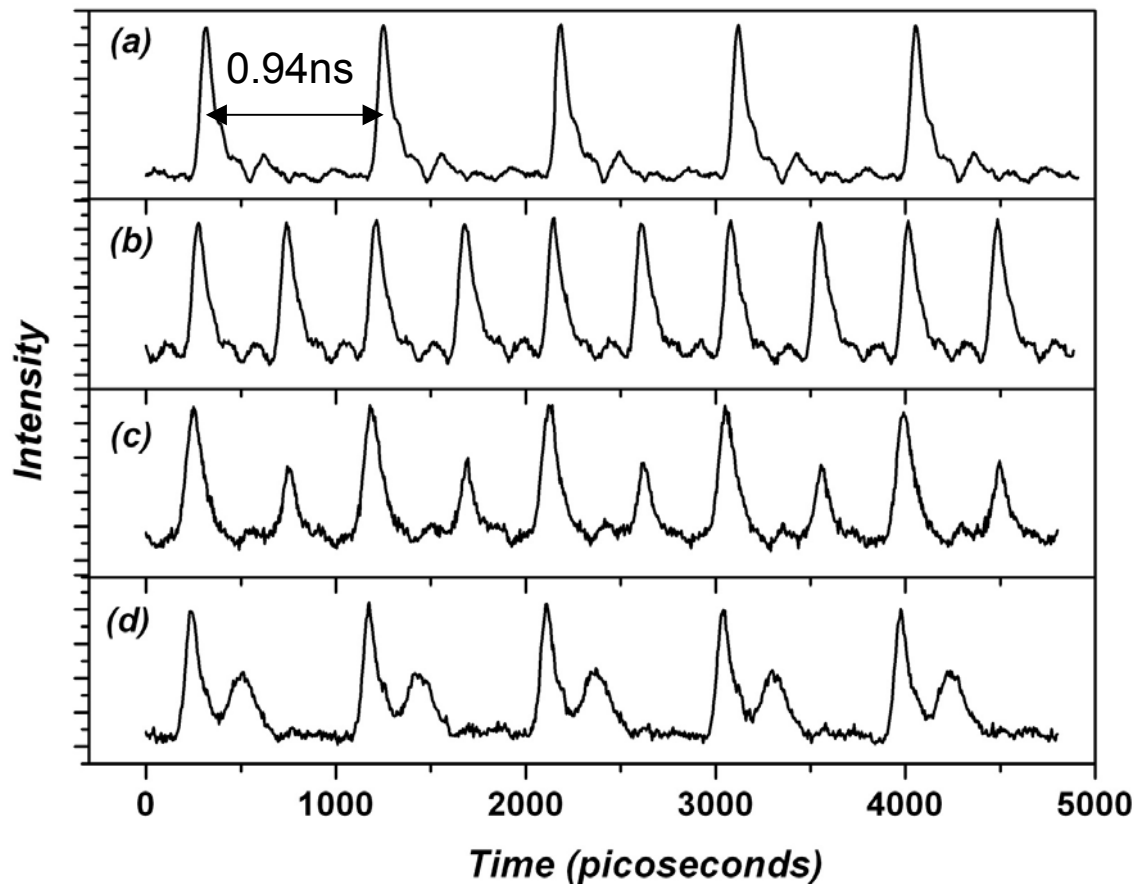




“Z-shape” Folded Cavity Configuration



- stable mode-locking at any current level beyond threshold
- 40mW average output power with an OC R~96%
- ~1W peak power, 1.1GHz rep. rate
- ~20 μ m spot size on SESAM

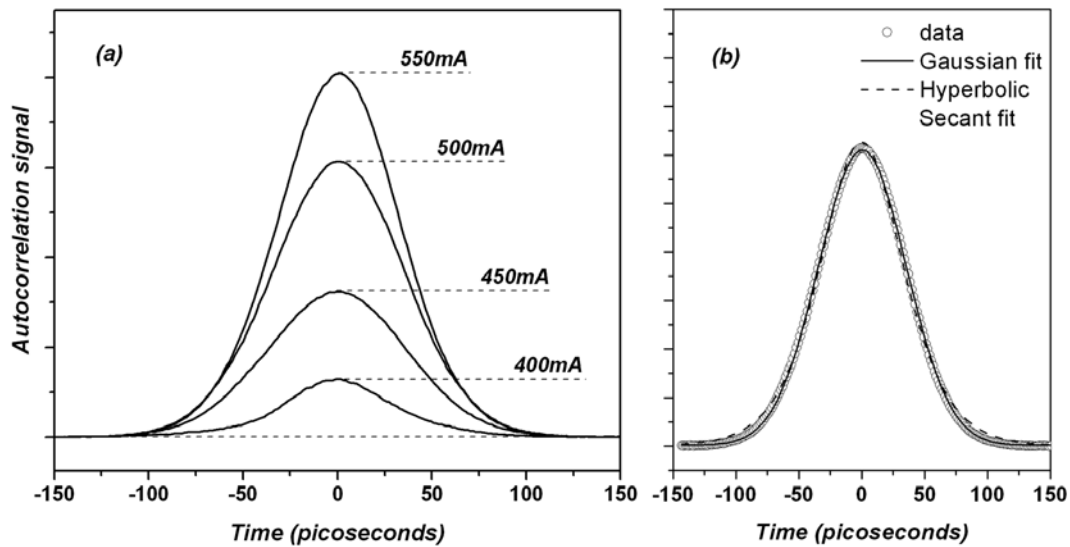


(photodiode output)



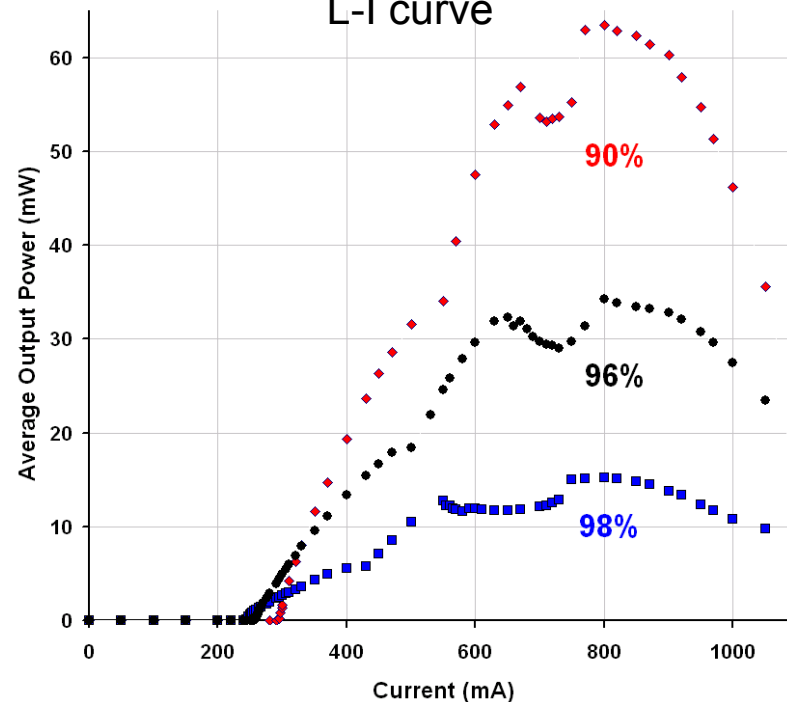
Pulse Width and L-I Measurements

Second-Harmonic Autocorrelation Measurement



- Pulse width of 57ps @500mA (limited by “extra” n-DBR)
- Fast saturable absorber regime

L-I curve

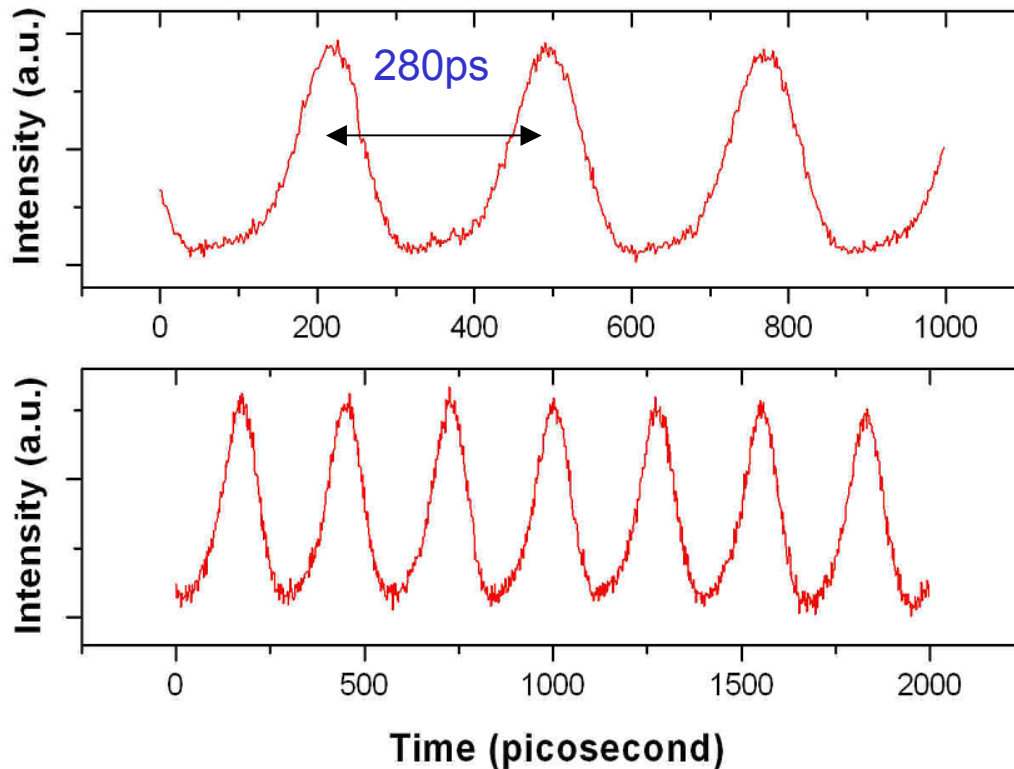
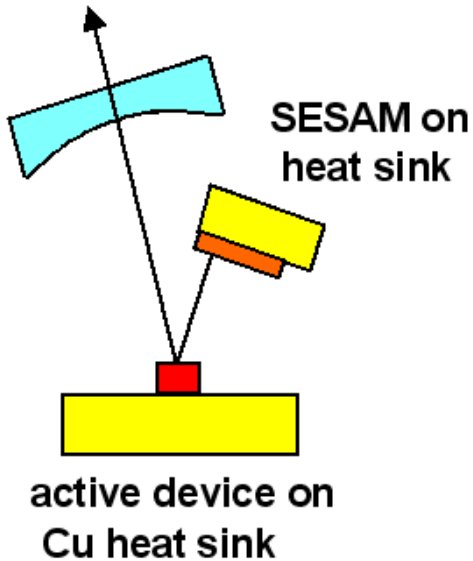


- Power scalable for different reflectance of output coupler
- Mode-locking achieved for R_{oc} as low as 90%



V-shape Folded Cavity Configuration

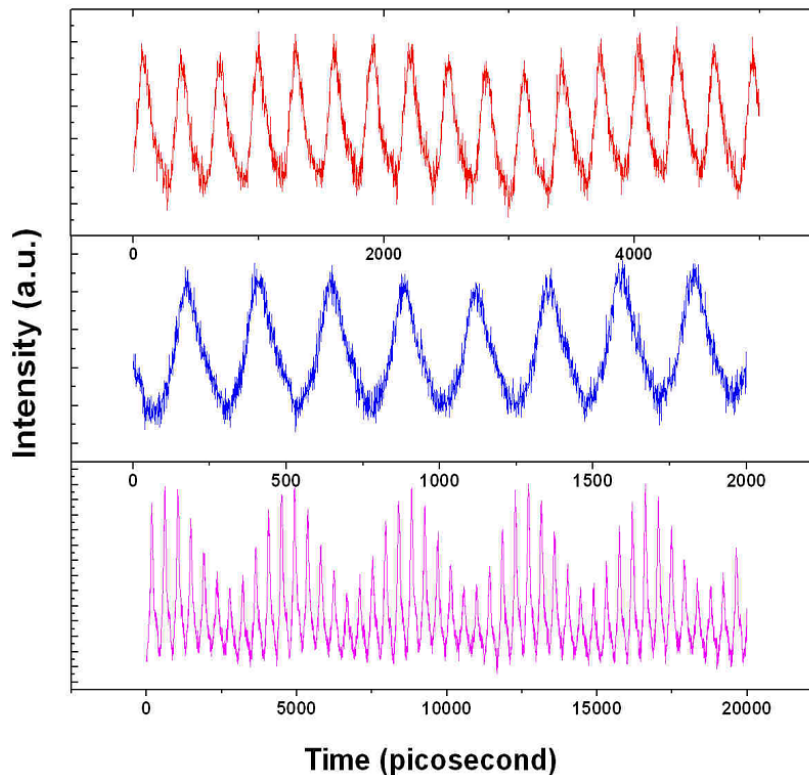
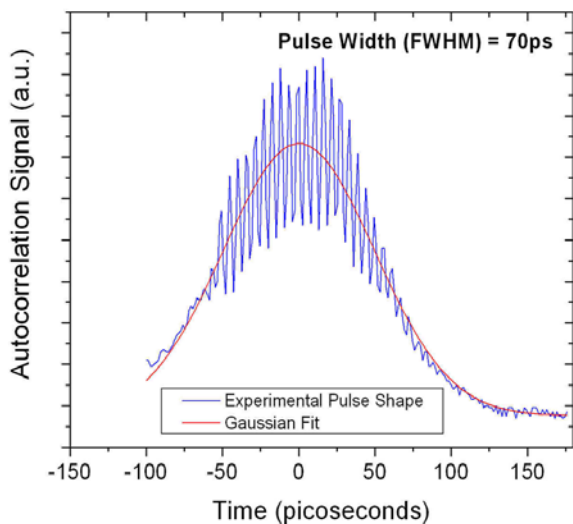
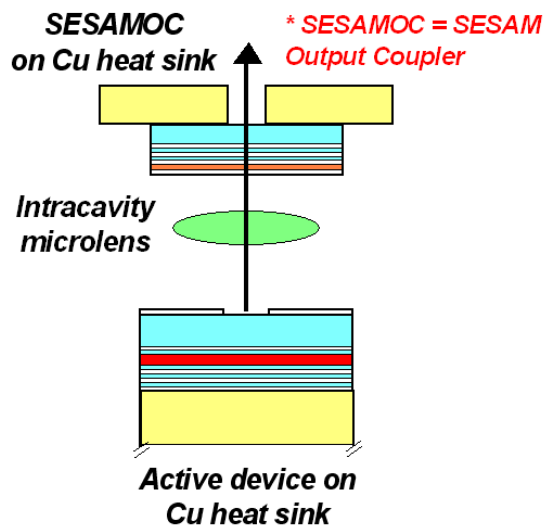
$R=0.96$, $ROC = 50\text{mm}$



- Shorter cavity length gives higher rep. rate ~ 3.6 GHz
- Comparable pulse width $\sim 60\text{ps}$ (limited by “extra DBR”)
- Less stable because of spot size on SESAM is larger



Linear Cavity Configuration



$$f_{\text{rep}} = 3.3\text{GHz}$$

$$f_{\text{rep}} = 4.5\text{GHz}$$

Gain switching-
and mode-
locking

- Linear cavity design with “SESAMOC” and intracavity lens delivers compact package size
- Preliminary rep. rate ranging from 1GHz to 4.5GHz, potential of reaching multi-GHz regime (10-100 GHz)



SUMMARY

- Demonstrated stable multi-GHz rate picosecond pulse generation by passive mode-locking of an extended cavity VCSEL
- Peak powers >1 W and pulsewidths ~ 50 psec achieved in linear, “Z” and “V”-cavities
- Device design properly balances saturation of absorption (intracavity SESAM) and saturation of gain
- Considerably higher repetition rates (up to 100 GHz) and shorter pulses (\sim psec) are possible by optimizing cavity design/parameters
- Goal: Monolithic integration of a passively modelocked VCSEL

Support by 
(Optocenters)